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U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number	Date	Name	
	1	2005/0190455 A1	09/01/2005	ROSTALSKI et al.	
	2	2005/0117224 A1	06/02/2005	SHAFER et al.	
	3	2002/0163629 A1	11/07/2002	SWITKES et al.	
	4	2003/0030916 A1	02/13/2003	SUENAGA	
	5	2005/0141098 A1	06/30/2005	SCHUSTER	
	6	2004/0000627 A1	01/01/2004	SCHUSTER	
	7	2005/0030506 A1	02/10/2005	SCHUSTER	
	8	2005/0217135 A1	10/06/2005	O'DONNELL et al.	
	9	2005/0217137 A1	10/06/2005	SMITH et al.	
	10	2005/0217703 A1	10/06/2005	O'DONNELL	
	11	2004/0075895 A1	04/22/2004	LIN	
	12	2004/0118184 A1	06/24/2004	VIOLETTE	
	13	2004/0125351 A1	07/01/2004	KRAUTSCHIK	
	14	2004/0180294 A1	09/16/2004	BABA-ALI et al.	
	15	2004/0169924 A1	09/02/2004	FLAGELLO et al.	
	18	2004/0227923 A1	11/18/2004	FLAGELLO et al.	
	18	2003/0174408 A1	09/18/2003	ROSTALSKI et al.	
	18	2004/0180299 A1	09/16/2004	ROLLAND et al.	
	18	2004/0109237 A1	06/10/2004	EPPLE et al.	
	20	2004/0257544 A1	12/23/2004	VOGEL et al.	
	21	2004/0263808 A1	12/30/2004	SEWELL	
	22	2005/0036183 A1	02/17/2005	YEO et al.	
	23	2005/0036184 A1	02/17/2005	YEO et al.	
	24	2005/0037269 A1	02/17/2005	LEVINSON	
	25	2005/0036213 A1	02/17/2005	MANN et al.	
	26	2004/0224265 A1	11/11/2004	ENDO et al.	
	27	2004/0224525 A1	11/11/2004	ENDO et al.	
	28	2005/0046934 A1	03/03/2005	HO et al.	
	29	2005/0048223 A1	03/03/2005	PAWLOSKI et al.	
	30	2004/0253547 A1	12/16/2004	ENDO et al.	

			Sheet <u>2</u> of _
31	2004/0253548 A1	12/16/2004	ENDO et al.
32	2005/0068639 A1	03/31/2005	PIERRAT et al.
33	2005/0073670 A1	04/07/2005	CARROLL
34	2005/0084794 A1	04/21/2005	MEAGLEY et al.
35	2005/0094116 A1	05/05/2005	FLAGELLO et al.
36	2005/0100745 A1	05/12/2005	LIN et al.
37	2004/0136494 A1	07/15/2004	LOF et al.
38	2004/0160582 AI	08/19/2004	LOF et al.
39	2004/0165159 A1	08/26/2004	LOF et al.
40	2004/0207824 A1	10/21/2004	LOF et al.
41	2004/0211920 A1	10/28/2004	MARIA DERKSEN et al.
42	2005/0036121 A1	02/17/2005	HOOGENDAM et al.
43	2004/0169834 A1	09/02/2004	RICHTER et al.
44	2004/0259040 A1	12/23/2004	ENDO et al.
45	2004/0114117 A1	06/17/2004	BLEEKER
46	2004/0259008 A1	12/23/2004	ENDO et al.
47	2005/0110973 A1	05/26/2005	STREEFKERK et al.
48	2005/0122497 A1	06/09/2005	LYONS et al.
49	2004/0119954 AI	06/24/2004	KAWASHIMA et al.
50	2005/0185269 A1	08/25/2005	EPPLE et al.
51	2005/0225737 A1	10/13/2005	WEISSENRIEDER et al.
52	2005/0132914 A1	06/23/2005	MULKENS et al.
53	2005/0134815 A1	06/23/2005	VAN SANTEN et al.
54	2005/0147920 A I	07/07/2005	LIN et al.
55	2005/0145803 AI	07/07/2005	HAKEY et al.
56	2005/0146694 A1	07/07/2005	TOKITA
57	2005/0146695 A1	07/07/2005	KAWAKAMI
58	2005/0153424 AI	07/14/2005	COON
59	2005/0190435 A1	09/01/2005	SHAFER et al.
60	2005/0158673 A1	07/21/2005	HAKEY et al.
61	2005/0164502 A1	07/28/2005	DENG et al.
62	2005/0270505 A1	12/08/2005	SMITH
63	2005/0174549 A1	08/11/2005	DUINEVELD et al.
64	2005/0175940 A1	08/11/2005	DIERICHS
65	2005/0042554 A1	02/24/2005	DIERICHS et al.
66	2005/0205108 A1	09/22/2005	CHANG et al.
64	2005/0213061 A1	09/29/2005	HAKEY et al.
68	2005/0213072 AI	09/29/2005	SCHENKER et al.
69	2005/0219499 A1	10/06/2005	MARIA ZAAL et al.

Sheet 3 of 6

70	2005/0219482 A1	10/06/2005	BASELMANS et al.
71	2005/0219481 A1	10/06/2005	COX et al.
72	2005/0024609 A1	02/03/2005	DE SMIT et al.
73	2005/0231694 A1	10/20/2005	KOLESNYCHENKO et al.
74	2005/0237501 A1	10/27/2005	FURUKAWA et al.
75	2005/0245005 A1	11/03/2005	BENSON
76	2005/0243292 A1	11/03/2005	BASELMANS et al.
77	2005/0253090 A1	11/17/2005	GAU et al.
78	2005/0007569 A1	01/13/2005	STREEFKERK et al.
79	2005/0259232 A1	11/24/2005	STREEFKERK et al.
80	2004/0233405 A1	11/25/2004	KATO et al.
81	2005/0259233 A1	11/24/2005	STREEFKERK et al.
82	2005/0007570 A1	01/13/2005	STREEFKERK et al.
83	2005/0264778 A1	12/01/2005	LOF et al.
84	2005/0002004 A1	01/06/2005	KOLESNYCHENKO et al.
85	2005/0030498 A1	02/10/2005	MULKENS
86	2004/0263809 A1	12/30/2004	NAKANO
87	2005/0018155 A1	01/27/2005	COX et al.
88	2005/0018156 A1	01/27/2005	MULKENS et al.
89	2005/0030497 A1	02/10/2005	NAKAMURA
90	2005/0134817 A1	06/23/2005	NAKAMURA
91	2005/0145265 A1	07/07/2005	RAVKIN et al.
92	2005/0041225 A1	02/24/2005	SENGERS et al.
93	2005/0046813 A1	03/03/2005	STREEFKERK et al.
94	2005/0048220 A1	03/03/2005	MERTENS et al.
95	2005/0030511 A1	02/10/2005	AUER-JONGEPIER et al.
96	2005/0078286 A1	04/14/2005	DIERICHS et al.
97	2005/0078287 A1	04/14/2005	SENGERS et al.
98	2005/0233081 A1	10/20/2005	TOKITA
99	2005/0052632 A1	03/10/2005	МІҰАЈІМА
100	2005/0088635 A1	04/28/2005	HOOGENDAM et al.
101	2005/0259236 A1	11/24/2005	STRAAIJER
102	2005/0094114 A1	05/05/2005	STREEFKERK et al.
103	2005/0094119 A1	05/05/2005	LOOPSTRA et al.
104	2005/0074704 AI	04/07/2005	ENDO et al.
105	2005/0128445 AI	06/16/2005	HOOGENDAM et al.
106	2005/0179877 AI	08/18/2005	MULKENS et al.
107	2005/0174550 A1	08/11/2005	STREEFKERK et al.
108	2005/0263068 AI	12/01/2005	HOOGENDAM et al.

Date: Octoberal 9-12096 FERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /ML/

						4 of _6
	109	2005/0106512 A1	05/19/2005	ENDO et al.		
	110	2005/0117135 A1	06/02/2005	VERHOEVEN et al.		
	111	2005/0175776 A1	08/11/2005	STREEFKERK et al.	-	
	112	2005/0122505 A1	06/09/2005	MIYAJIMA	-	
	113	2005/0146693 A1	07/07/2005	OHSAKI		
11.00	114	2005/0136361 A1	06/23/2005	ENDO et al.		
	115	2005/0259234 A1	11/24/2005	HIRUKAWA et al.		
	116	2006/0139614 A1	06/29/2006	OWA et al.		
	117	4,346,164	08/24/1982	TABARELLI et al.		
	118	4,480,910	11/06/1984	TAKANASHI et al.		
	119	5,825,043	10/20/1998	SUWA		
	120	5,715,039	02/03/1998	FUKUDA et al.		
		FOREIG	ON PATENT DOCU	MENTS	,	,
Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation
	121	JP A 57-153433	09/22/1982	JAPAN	x	х
	122	JP A 58-202448	11/25/1983	JAPAN	х	x
	123	JP A 59-019912	02/01/1984	JAPAN	х	x
	124	JP A 62-065326	03/24/1987	JAPAN	х	x
	125	JP A 63-157419	06/30/1988	JAPAN	х	х
	126	JP A 04-305915	10/28/1992	JAPAN	х	х
	127	JP A 04-305917	10/28/1992	JAPAN	х	x
	128	JP A 05-062877	03/12/1993	JAPAN	x	x
	129	JP A 07-220990	08/18/1995	JAPAN	х	х
	130	JP A 10-303114	11/13/1998	JAPAN	x	х
	131	JP A 10-340846	12/22/1998	JAPAN	х	х
	132	JP A 11-176727	07/02/1999	JAPAN	x	х
	133	JP A 2000-058436	02/25/2000	JAPAN	х	х
	134	JP A 06-124873	05/06/1994	JAPAN	х	х
	135	JP A 08-316125	11/29/1996	JAPAN	х	x
	136	WO 2004/019128 A2	03/04/2004	WIPO		
	137	WO 2002/091078 A1	11/14/2002	WIPO		
	138	WO 2004/077154 A2	09/10/2004	WIPO		
	139	WO 2003/077037 A1	09/18/2003	WIPO		-
	140	WO 2004/081666 A1	09/23/2004	WIPO		
	141	WO 2005/001432 A2	01/06/2005	WIPO		
	142	WO 2004/093159 A2	10/28/2004	WIPO		
	143	WO 2004/090634 A2	10/21/2004	WIPO		
	144	WO 2004/090633 A2	10/21/2004	WIPO		

145	WO 2004/092833 A2	10/28/2004	WIPO		
146	WO 2004/093160 A2	10/28/2004	WIPO		
147	WO 2004/090577 A2	10/21/2004	WIPO		
148	WO 2004/092830 A2	10/28/2004	WIPO		
149	WO 2004/093130 A2	10/28/2004	WIPO		
150	WO 2004/095135 A2	11/04/2004	WIPO		
151	WO 2005/003864 A2	01/13/2005	WIPO		
152	WO 2005/006026 A2	01/20/2005	WIPO		
153	WO 2005/008339 A2	01/27/2005	WIPO		
154	WO 2005/013008 A2	02/10/2005	WIPO		
155	WO 2005/017625 A2	02/24/2005	WIPO		
156	WO 2005/015283 AT	02/17/2005	WIPO		
157	WO 2005/019935 A2	03/03/2005	WIPO		
158	WO 2005/024325 A2	03/17/2005	WIPO		
159	WO 2005/022266 A2	03/10/2005	WIPO		
160	WO 2005/024517 A2	03/17/2005	WIPO		
161	WO 2005/034174 A2	04/14/2005	WIPO		
162	WO 2004/055803 A1	07/01/2004	WIPO		
163	WO 2004/057589 A1	07/08/2004	WIPO		
164	WO 2004/057590 A1	07/08/2004	WIPO		
165	WO 2005/054953 A2	06/16/2005	WIPO		
166	WO 2005/054955 A2	06/16/2005	WIPO		
167	WO 2005/062128 A2	07/07/2005	WIPO		
168	WO 2005/059617 A2	06/30/2005	WIPO		
169	WO 2005/059654 A1	06/30/2005	WIPO		
170	WO 2005/059645 A2	06/30/2005	WIPO		
171	WO 2005/059618 A2	06/30/2005	WIPO		ļ
172	WO 2005/064405 A2	07/14/2005	WIPO		
173	WO 2005/064400 A2	07/14/2005	WIPO		
174	WO 2005/069055 A2	07/28/2005	WIPO		
175	WO 2005/069081 A2	07/28/2005	WIPO		
176	WO 2005/071491 A2	08/04/2005	WIPO		
177	WO 2005/074606 A2	08/18/2005	WIPO		
178	WO 2005/076084 A1	08/18/2005	WIPO	ļ	
179	WO 2005/081067 A1	09/01/2005	WIPO	ļ	
180	WO 2005/081030 A1	09/01/2005	WIPO		<u> </u>
181	WO 2005/069078 A1	07/28/2005	WIPO		ļ
182	WO 2005/050324 A2	06/02/2005	WIPO	<u> </u>	

184	WO 2005/098505 A1	10/20/2005	WIPO	
185	WO 2005/098506 A1	10/20/2005	WIPO	
186	WO 2005/106589 A1	11/10/2005	WIPO	 . ,
187	WO 2005/111722 A2	11/24/2005	WIPO	 7.
188	WO 2005/111689 A2	11/24/2005	WIPO	
189	WO 2005/119368 A2	12/15/2005	WIPO	
 190	WO 2005/119369 A1	12/15/2005	WIPO	
191	WO 2005/001572 A2	01/06/2005	WIPO	
192	WO 2005/048328 A1	05/26/2005	WIPO	
 193	WO 2005/062351 A1	07/07/2005	WIPO	
194	DD 221 563 A1	04/24/1985	GERMANY	x
195	DD 224 448 A1	07/03/1985	GERMANY	x
 		OTHER DOCUME	NTS	

Initials	No.	(,			
	196	Lin, B.J. "Semiconductor Foundry, Lithography, and Partners." Proceedings of SPIE, Vol.	688, pp. 11 - 24, 2002.		
_	197	Switkes, M., et al. "Resolution Enhancement of 157nm Lithography by Liquid Immersion." 4691, pp. 459 - 465, 2002.	i, M., et al. "Resolution Enhancement of 157nm Lithography by Liquid Immersion." Proceedings of SPIE, Vol. p. 459 - 465, 2002.		
	198	Switkes, M., et al. "Resolution Enhancement of 157nm Lithography by Liquid Immersion." Microsyst., Vol. 1, No. 3, pp. 1 - 4, 2002.	J. Microlith., Microfab.,		
	199	Owa, Soichi, et al. "Nikon F2 Exposure Tool," slides 1 - 25, 3rd 157nm Symposium, Septer	nber 4, 2002.		
	200	Owa, Soichi. "Immersion Lithography," slides 1 - 24, Immersion Lithography Workshop, December 11, 2002. Owa, Soichi, et al. "Immersion Lithography, its Potential Performance and Issues." Proceedings of SPIE, Vol. 5040, 724 - 733, 2003.			
	201				
	Owa, Soichi, et al. "Potential Performance and Feasibility of Immersion Lithography," slides 1 - 33, NGL V July 10, 2003.				
	203	Owa, Soichi, et al. "Update on 193nm Immersion Exposure Tool," slides 1 - 38, Immersion 2004.	- 38, Immersion Workshop 2004, January 27,		
Owa, Soichi, et al. "Update on 193nm Immersion Exposure Tool," slides 1 - 51, Litho Forum, January 28					
EXAMINER	. /Mich	nael Liu/	DATE CONSIDERED 07/03/2008		
Examiner:		Ficitation considered, whether or not citation is in conformance with M.P.E.P. 609; draw ance and not considered. Include copy of this form with next communication to applicant.	line through citation if not in		